

CLAIMS

WHAT IS CLAIMED IS

1. A work chamfering apparatus for chamfering a work,
5 comprising:

a work holding portion including a first surface and
a second surface respectively contacting a main surface
and another main surface of the work, for holding the work;

wherein the first surface includes a portion having
10 a static friction coefficient greater than 0.1.

2. The apparatus according to Claim 1, wherein the
portion having the static friction coefficient greater
than 0.1 is formed at two end portions of the first
15 surface, the two end portions contacting the work.

3. The apparatus according to Claim 1 or 2, wherein the
portion having the static friction coefficient greater
than 0.1 has a holding grain projecting out of the first
20 surface.

4. A work chamfering apparatus for chamfering a work,
comprising:

a work holding portion including a first surface and
25 a second surface respectively contacting a main surface
and another main surface of the work, for holding the work;

wherein the first surface includes a center portion
and two end portions, each of the two end portions having

the portion having the static friction coefficient greater than 0.1 is formed at two end portions of the first surface, and

the two end portions contacting the work in the first step.

9. The method according to Claim 7 or 8, wherein the portions having the static friction coefficient greater than 0.1 stick into the work in the first step.

10. A work chamfering method using a work holding portion including a first surface and a second surface, the first surface including a center portion and two end portions, each of the two end portions having a static friction coefficient greater than that of the center portion, the method comprising:

a first step of holding the work with the work holding portion by contacting each of the two end portions of the first surface with a main surface of the work and contacting the second surface with another main surface of the work; and

a second step of chamfering the work by using a tool.

11. The method according to one of Claims 7 through 10, the second surface contacts the work at a plurality of locations, with a center of rotation of the work in between, in the first step.

12. The method according to one of Claims 7 through 11,
wherein

the tool includes a first grinding stone and a second
grinding stone, and

5 the second step includes a sub-step of chamfering one
edge of the work with the first grinding stone, a sub-step
of moving the tool thickness-wise of the work, and a
sub-step of chamfering another edge of the work with the
second grinding stone.

10 13. The method according to Claim 7, wherein the work is
a R-Fe-B alloy containing cobalt at a rate not smaller than
0.3 wt% and not greater than 10 wt%.

15 14. The method according to Claim 7, wherein
the tool includes a grinding stone, and
the grinding stone being rotated at a speed not slower
than 2000 rpm and not faster than 5000 rpm for chamfering
the work in the second step.

20 15. The method according to Claim 7, wherein
the tool includes a grinding stone, and
the grinding stone being rotated at a circumferential
speed not slower than 125.6 m/min and not faster than 314
25 m/min for chamfering the work in the second step.

16. A chamfering method for chamfering a rare-earth sintered magnet by using a rotating grinding stone, wherein

the grinding stone is rotated at a speed not slower
5 than 2000 rpm and not faster than 5000 rpm and relative speed of the grinding stone with respect to an outer circumferential portion of the rare-earth sintered magnet is not slower than 0.5 mm/sec and not faster than 7.0 mm/sec, for chamfering the rare-earth sintered magnet.

17. A chamfering method for chamfering a rare-earth sintered magnet by using a rotating grinding stone, wherein

the grinding stone is rotated at a circumferential
15 speed not slower than 125.6 m/min and not faster than 314 m/min and relative speed of the grinding stone with respect to an outer circumferential portion of the rare-earth sintered magnet is not slower than 0.5 mm/sec and not faster than 7.0 mm/sec, for chamfering the
20 rare-earth sintered magnet.

18. The method according to Claim 16 or 17, wherein the grinding stone includes an abrasive grain having an average diameter not smaller than 100 μ m and not greater
25 than 270 μ m.

19. The method according to Claim 16 or 17, wherein a coolant having a surface tension not smaller than 25 mN/m

and not greater than 60 mN/m is supplied to a grinding region.

20. The method according to Claim 16 or 17, wherein the
5 rare-earth sintered magnet contains cobalt at a rate not
smaller than 0.3 wt% and not greater than 10 wt%.

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